AN

	Application No.	Applicant(s)
Notice of Allowability		
	10/730,094 Examiner	MIURA, NORIYUKI Art Unit
	Remmon R. Fordé	2826
The MAILING DATE of this communication appe All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	ears on the cover sheet with the co (OR REMAINS) CLOSED in this ap or other appropriate communication GHTS. This application is subject to	orrespondence address plication. If not included n will be mailed in due course. THIS
1. This communication is responsive to 12/09/2003.		/
2. The allowed claim(s) is/are <u>1-5</u> .		
3. \boxtimes The drawings filed on <u>09 December 2003</u> are accepted by	the Examiner.	$\mathcal{A}/$
4. Acknowledgment is made of a claim for foreign priority una a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give 6. CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftspers 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the 7. DEPOSIT OF and/or INFORMATION about the depose attached Examiner's comment regarding REQUIREMENT is	been received. been received in Application Notice cuments have been received in this of this communication to file a reply ENT of this application. itted. Note the attached EXAMINER es reason(s) why the oath or declarate t be submitted. on's Patent Drawing Review (PTO- a Amendment / Comment or in the Comment or in the Comment of the drawing he header according to 37 CFR 1.121(sit of BIOLOGICAL MATERIAL resuments.)	complying with the requirements 'S AMENDMENT or NOTICE OF stion is deficient. 948) attached Office action of sin the front (not the back) of d). must be submitted. Note the
 Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 12/09/2003 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material 	6. ☐ Interview Summary Paper No./Mail Da 8), 7. ☑ Examiner's Amendr	Patent Application (PTO-152) (PTO-413), te ment/Comment ent of Reasons for Allowance

EXAMINER'S AMENDMENT

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Adam C. Volentine on 12/10/2004.

The application has been amended as follows:

Claims

In claim 4, line 16, remove "; and" replace with ---.--

Reasons For Allowance

The following is an examiner's statement of reasons for allowance:

Claims 1-5 are allowed.

Claim 1 recites a semiconductor device structure including the specific structural limitations of providing a buried insulating film formed in that region of the SOI layer which lies between the source region and the drain region and under the gate insulating film; and a non-doped silicon film formed between the buried insulating film and the gate insulating film in contact with a top surface of the buried insulating film and serving as a channel region. The abovementioned structural limitations are neither anticipated by

nor obvious over the prior art of record. Likewise, claims 2-5 are also allowable as being dependent upon allowable claim 1.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Relevant Prior Art

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

Ikeda, Adan and Ono each recite SOI semiconductor devices.

Contact Information

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Remmon R. Fordé whose telephone number is (571) 272-1916. The examiner can normally be reached on Monday-Thursday (8:00-6:30).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nathan J. Flynn can be reached on (571) 272-1915. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Remmon R. Fordé